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In re Application of:

Rivoire, et al.

Serial No.: 09/844,991

Filed:

April 27, 2001

Confirmation No.: 1361

For:

Method for Planarizing

Organosilicate Layers

Commissioner for Patents Washington, D.C. 20231

Dear Sir:

Group Art Unit: 3723

Examiner:

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37 CFR 1.8

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Patent Counsel

Applied Materials, Inc.

P.O. Box 450A

Santa Clara, CA 95052

Attached is a copy of the Filing Receipt with the above change noted thereon. Please correct this error or notify the applicants of the reasons for denying the request.

Respectfully submitted,

B. Todd Patterson

Registration No. 37,906

MOSER, PATTERSON & SHERIDAN, L.L.P.

3040 Post Oak Blvd., Suite 1500

Houston, TX 77056

Telephone: (713) 623-4844 Facsimile: (713) 623-4846 Attorney for Applicants





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Patent Counsel Applied Materials, Inc.

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CONFIRMATION NO. 1361 UPDATED FILING RECEIPT

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Applicant(s)

Maurice Rivoire, Meylan, FRANCE; \ Frederic Gaillard, Meylan, FRANCE; Charles Lutti, Grenoble, FRANCE;

Ellie Yieh, San Jose, CA; 🗸

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Assignment For Published Patent Application

Applied Materials, Inc.;

Domestic Priority data as claimed by applicant

Foreign Applications

If Required, Foreign Filing License Granted 06/21/2001

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Early Publication Request: No

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Method for planarizing organosilicate layers $\stackrel{\checkmark}{}$

Preliminary Class

451

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